AMENDMENTS TO THE CLAIMS

1. **(Original)** A method of cleaning a surface, comprising applying water containing no more than 1 ppm gas to the surface to disperse or dissolve dirt on the surface in the water.

2. **(Original)** A method according to claim 1, wherein the water contains no more than about 0.9 ppm gas.

3. **(Original)** A method according to claim 1, wherein the water contains no more than about 0.3 ppm gas.

4. **(Original)** A method according to claim 1, wherein the water contains no more than about 3 ppb gas.

5. **(Original)** A method according to claim 1, wherein the water contains no more than about 0.3 ppb gas.

6. **(Currently amended)** A method according to claim 1 ~~any one of the preceding claims~~, wherein the surface is on an article and wherein the method comprises cleaning the article in the water in a container.

7. **(Original)** A method according to claim 6, wherein one or both of the article and water are agitated.

8. **(Currently amended)** A method according to claim 1 ~~any one of the preceding claims~~, wherein the water is applied to the surface by spraying.

9. **(Original)** A method according to claim 8, wherein the water is sprayed on to the surface by means of an airless spray system.

10. **(Currently amended)** A method according to claim 1 ~~anyone of claims 1 to 5~~, which comprises applying multiple streams of the water to the surface to agitate dirt on the surface.

11. **(Currently amended)** A method according to claim 1 ~~any one of the preceding claims~~, wherein the water contains hydrophilic stabilising material to alleviate redeposition of the dirt on the surface.

12. **(Currently amended)** A method according to claim 1 ~~any one of the preceding claims~~, which comprises using a stored source of the water containing no more than 1 ppm gas.

13. **(Currently amended)** A method according to claim 1 ~~any one of claims 1 to 11~~, which includes de-gassing a source of water to a level of no more than 1 ppm gas.

14. **(Currently amended)** A method according to claim 1 ~~any one of the preceding claims~~, which comprises dissolving hydrophobic dirt on the surface using a non-aqueous solvent, and dispersing the non-aqueous solvent and dissolved hydrophobic dirt in the water.

15. **(Original)** A method according to claim 14, wherein the non-aqueous solvent is applied to the surface prior to applying the water to the surface.

16. **(Original)** A method according to claim 15, wherein the surface is relatively separated from a liquid body of the non-aqueous solvent prior to applying the water to the surface.

17. **(Currently amended)** A method according to claim 14 ~~any one of claims 14 to 16~~ wherein the non-aqueous solvent applied to the surface contains no more than about 10 ppm gas.

18. **(Original)** A method according to claim 17, wherein the non-aqueous solvent applied to the surface contains no more than about 1 ppm gas.

19. **(Original)** A method according to claim 17, wherein the non-aqueous solvent applied to the surface contains no more than about 0.3 ppm gas.

20. **(Original)** A method according to claim 17, wherein the non-aqueous solvent applied to the surface contains no more than about 3 ppb gas,

21. **(Original)** A method according to claim 17, wherein the non-aqueous solvent applied to the surface contains no more than about 0.3 ppb gas.

22. **(Currently amended)** A method according to claim 17 ~~any one of claims 17 to 21~~, which comprises using a stored source of the non-aqueous solvent containing no more than 10 ppm gas.

23. **(Currently amended)** A method according to claim 17 ~~any one of claims 17 to 21~~, which includes de-gassing the non-aqueous solvent to a level of no more than 10 ppm gas.

24. **(Currently amended)** A method according to claim 14 ~~any one of claims 14 to 23~~, wherein the non-aqueous solvent is hydrophobic.

25. **(Currently amended)** A method according to claim 14 ~~any one of claims 14 to 24~~, wherein the non-aqueous solvent is selected from hydrocarbons, fluorocarbons, chloro-hydrocarbons, silicone liquids and mixtures of one or more of same.

26. **(Original)** A method according to claim 25, wherein the non-aqueous solvent is selected from dodecane, squalene, hexamethyldisiloxane, perfluorohexane, hexane and mixtures of one or more of same.

27. **(Original)** Apparatus for cleaning a surface, comprising a source of water containing no more than 1 ppm gas and a dispenser for applying the water to the surface.

28. **(Original)** Apparatus according to claim 27, wherein the surface is on an article and the apparatus includes a container for receiving the article.

29. **(Original)** Apparatus according to claim 28, which includes an agitator for one or both of the article and water.

30. **(Currently amended)** Apparatus according to claim 27 ~~any one of claims 27 to 29~~, wherein the dispenser comprises a sprayer.

31. **(Original)** Apparatus according to claim 30, wherein the sprayer is part of an airless spray system.

32. **(Currently amended)** Apparatus according to claim 27 ~~any one of claims 27 to 29~~, wherein the dispenser applies multiple streams of the water to the surface to agitate dirt on the surface.

33. **(Currently amended)** Apparatus according to claim 27 ~~any one of claims 27 to 32~~, wherein the source of water comprises a store of the water containing no more than 1 ppm gas.

34. **(Currently amended)** Apparatus according to claim 27 ~~any one of claims 27 to 33~~, wherein the source of water comprises equipment for de-gassing water to a level of no more than 1 ppm gas.

35. **(Currently amended)** Apparatus according to claim 27 ~~any one of claims 27 to 34~~, which includes a source of non-aqueous solvent and a dispenser for applying the non-aqueous solvent to the surface.

36. **(Original)** Apparatus according to claim 35, wherein one dispenser is used for applying the water and the non-aqueous solvent.

37. **(Currently amended)** Apparatus according to claim 35 ~~or 36~~, wherein the source of the non-aqueous solvent comprises a store of the non-aqueous solvent.

38. **(Currently amended)** Apparatus according to claim 35 ~~any one of claims 35 to 37~~, wherein the source of nonaqueous solvent comprises equipment for de-gassing non-aqueous solvent to a level of no more than 10 ppm gas.